

REMARKS

Claims 20-26 are currently pending, wherein claims 20 and 21 have been amended. Applicant respectfully request favorable reconsideration in view of the remarks present herein below.

In paragraph 1 of the Office Action (“Action”), the Examiner objects to claim 20 because of various informalities. In response, Applicant hereby amends claim 20 as suggested by the Examiner, thereby addressing the Examiner’s concerns.

In paragraph 3 of the Action, the Examiner rejects claim 21 under 35 U.S.C. §112, second paragraph, as being indefinite. More specifically, the Examiner asserts that the step of depositing a semiconductor material on the gate insulating film and then patterning the semiconductor material to form an active layer, and to form an ohmic contact layer of the thin film transistor is confusing. Claim 21 has been amended to more clearly define the present invention, thereby addressing the Examiner’s concerns. Accordingly, Applicant respectfully requests reconsideration and withdrawal of the rejection of claim 21 under 35 U.S.C. §112, second paragraph.

The application is in condition for allowance. Notice of same is earnestly solicited. Should the Examiner find the application other than in condition for allowance, the Examiner is requested to call the undersigned attorney at (202) 496-7500 to discuss the steps necessary for placing the application in condition for allowance. All correspondence should continue to be sent to the below-listed address.

If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time, or any other fees required to complete the filing of this response, may be charged to Deposit Account No. 50-0911. Please

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credit any overpayment to deposit Account No. 50-0911. A duplicate copy of this sheet is enclosed.

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Respectfully submitted,

By 
Rebecca Goldman Rudich

Registration No.: 41,786
MCKENNA LONG & ALDRIDGE LLP
1900 K Street, N.W.
Washington, DC 20006

Attorney for Applicants